

Special Issue

Wafer Level Packaging of MEMS

Message from the Guest Editor

Packaging is essential for the practical use of MEMS, in terms of performance and reliability. The electronics market has been continuously requiring the downsizing and cost reduction of MEMS, and, thus, wafer-level packaging is becoming more important and replacing conventional die-level packaging. One of important features of the wafer-level packaging of MEMS is that it often needs the device cavity, which is hermetically sealed. Therefore, hermetic/vacuum sealing and electrical feedthrough from the sealed cavity are key technologies. On the other hand, emerging devices need new types of packaging, for example, biocompatible and flexible packaging, which are also attracting a great deal of attention. Test, reliability control, wiring, dicing, chip-level integration and material development related to the wafer-level packaging of MEMS are also included in the scope of this Special Issue. Wafer-level packaging is strongly connected to the integration of multiple components, and, thus, papers about wafer-level integration are also welcome.

Guest Editor

Prof. Dr. Shuji Tanaka

Department of Robotics, Graduate School of Engineering, Tohoku University 6-6-01 Aramaki Aza Aoba, Aoba-ku, Sendai, Miyagi 980-8579, Japan

Deadline for manuscript submissions

closed (15 March 2018)



Micromachines

an Open Access Journal
by MDPI

Impact Factor 3.0
CiteScore 6.0
Indexed in PubMed



mdpi.com/si/11090

Micromachines
Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland
Tel: +41 61 683 77 34
micromachines@mdpi.com

[mdpi.com/journal/
micromachines](https://mdpi.com/journal/micromachines)





Micromachines

an Open Access Journal
by MDPI

Impact Factor 3.0
CiteScore 6.0
Indexed in PubMed



[mdpi.com/journal/
micromachines](https://mdpi.com/journal/micromachines)



About the Journal

Message from the Editor-in-Chief

You are invited to contribute research articles or comprehensive reviews for consideration and publication in *Micromachines* (ISSN 2072-666X). *Micromachines* is published in the open access format. Research articles, reviews and other contents are released on the internet immediately after acceptance. The scientific community and the general public have unlimited free access to the content as soon as it is published. As an open access journal, *Micromachines* is supported by the authors or their institutes by payment of article processing charges (APC) for accepted papers. We are pleased to welcome you as our authors.

Editor-in-Chief

Prof. Dr. Ai-Qun Liu

1. Department of Electrical and Electronic Engineering, The Hong Kong Polytechnic University, Hong Kong, China

2. School of Electrical and Electronic Engineering, Nanyang Technological University, Singapore 639798, Singapore

Author Benefits

High Visibility:

indexed within Scopus, SCIE (Web of Science), PubMed, PMC, Ei Compendex, dblp, and other databases.

Journal Rank:

JCR - Q2 (Instruments and Instrumentation) / CiteScore - Q1 (Mechanical Engineering)

Rapid Publication:

manuscripts are peer-reviewed and a first decision is provided to authors approximately 17.2 days after submission; acceptance to publication is undertaken in 1.9 days (median values for papers published in this journal in the first half of 2025).